

FOUR-POINT PROBE RESISTIVITY MEASUREMENT

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ABSTRACT

Today's research and manufacturing are being pressured to improve productivity while reducing costs. Testing and measurement must be accomplished in the shortest possible time and in repeatable manner.

This project describes the design and construction of a Four-Point Probe Resistivity Measurement unit with moveable probe. This measurement method is the most widely employed in practice. The system consists of two main parts namely oscillator and mixer circuit.

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<u>CONTENTS</u>	<u>PAGES</u>
ABSTRACT	i
ACKNOWLEDGEMENT	ii
CONTENTS	iii
1.0 INTRODUCTION	1
2.0 METHOD OF MEASURING RESISTIVITY	3
2.1 One-point Probe	3
2.2 Two-point Probe	5
2.3 Four-point Probe	6
2.4 Four-point Probe Instrumentation	10

CHAPTER 1

1.0 INTRODUCTION

Resistivity is a specific property of a material and it is an important material parameter especially semiconductor material. The resistance of a piece of metal or semiconductor is given by:

$$R = \rho \frac{l}{A} \quad (1.0)$$

Where,

l is the length of the material

A is the cross-sectional area

ρ is the resistivity

The resistivity is a macroscopic property that depends on the density of electron and holes and their mobilities.

The measured resistivity required in determining the doping can be obtained in a number of different ways. A seemingly straightforward approach would be to form the semiconductor into a bar as in Figure 1.0.